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APPLICATION NO. FILING DATE FIRST NAMED INVENTOR ATTORNEY DOCKET NO. CONFIRMATION NO. 10/699,298 10/31/2003 Binod B. De 335.7735USU 5394 09/27/2004 EXAMINER Paul D. Greeley, Esq. KEEHAN, CHRISTOPHER M Ohlandt, Greeley, Ruggiero & Perle, L.L.P. 10th Floor PAPER NUMBER ART UNIT One Landmark Square 1712 Stamford, CT 06901-2682

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	
Office Action Summary	10/699,298	DE ET AL.	
	Examiner	Art Unit	
	Christopher M. Keehan	1712	ľ
The MAILING DATE of this communication appeared for Reply			ddress
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status			
1) Responsive to communication(s) filed on 31 C	Octobor 2002		
	s action is non-final.		
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.			
Disposition of Claims			
4) Claim(s) 1-68 is/are pending in the application. 4a) Of the above claim(s) is/are withdraw 5) Claim(s) is/are allowed. 6) Claim(s) 1-68 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or Application Papers 9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) access applicant may not request that any objection to the ore Replacement drawing sheet(s) including the correction in the oregin access and access applicant may not request that any objection to the oregin access and access are also access and access access and access are also access and access access and access access and access access access and access access access and access acce	wn from consideration. r election requirement. r. epted or b) objected to by the led and the drawing of the	e 37 CFR 1.85(a). ected to. See 37 C	FR 1.121(d). ΓΟ-152.
Priority under 35 U.S.C. § 119		•	
 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the prior application from the International Bureau * See the attached detailed Office action for a list of 	s have been received. s have been received in Application ity documents have been received (PCT Rule 17.2(a)).	on No d in this National	Stage
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 10/31/03, 6/17/04.	4) Interview Summary (Paper No(s)/Mail Da 5) Notice of Informal Pa 6) Other:	te)-152)

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DETAILED ACTION

Examiner's Comments

There are two claim 23's. The second claim 23 has been treated as claim 24.

Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claims 1-68 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention. In claims 1 and 2, on pages 57, 59, 60, and 61, applicant has claimed structures that are not clearly defined. For example, in Structures (IA), (IB), and (IC), applicant has claimed a carboxylic group with parentheses. However, it is not clear what is meant by the parentheses. Normally, this would indicate a polymeric chain but there is no indication that this is the case. Structures (III), (IV), and (VI) also contain these parentheses (pages 59 and 60).

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

⁽b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1, 2, 6, 7, 17, and 18 are rejected under 35 U.S.C. 102(b) as being anticipated by Bonafini, Jr., et al., hereinafter Bonafini et al. (6,586,548 B2). The examiner is relying on the provisional application date of Bonafini et al., which, upon review, supports the cited application. Bonafini et al. disclose Structure (I) comprising one or more repeating units selected from the group as claimed (col.3, line 33-col.4, line 14), and a second repeating unit as claimed (col.5, line 66-col.6, line 53).

Claims 1, 2, 6, 7, 17, 18, 22, 23, 27, 28, 38, 39, 44, 45, 49, 50, 60, 61, and 65-67 are rejected under 35 U.S.C. 102(b) as being anticipated by Gonsalves (US 2002/0182541 A1). The examiner is relying on the provisional application date of Gonsalves, which, upon review, supports the cited application. Gonsalves discloses Structure (I) comprising one or more repeating units selected from the group as claimed and a second repeating unit as claimed (sections 0060-0062, 0068-0074, section 0079, and Figure 1).

Regarding claims 22, 23, 27, 28, 38 and 39, Gonsalves discloses a photosensitive composition comprising the copolymer as claimed, a photoacid generator, and a solvent (Example 14 and Table 4).

Regarding claims 44, 45, 49, 50, 60, 61, and 65-67, Gonsalves discloses the process and substrate as claimed (Example 19).

Claim Rejections - 35 USC § 103

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The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 3 and 10-12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Bonafini et al. Bonafini et al., as applied above, are as set forth and incorporated herein. Bonafini et al. do not appear to specifically disclose a weight average molecular weight and level of silicon as claimed. However, Bonafini et al. do disclose adding monomer levels of the polysilsesquioxane at 5 to 60% by weight of the monomeric mixture to provide copolymers with sufficient rigidity and hardness(col.5, lines 58-65). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to have added a variety of amounts of polysilsesquioxane, including an amount that would produce a weight average molecular weight and level of silicon included in applicant's claimed ranges, through routine experimentation and optimization. A particular parameter must first be recognized as a result-effective variable, i.e., a variable which achieves a recognized result, before the determination of the optimum or workable ranges of said variable might be characterized as routine experimentation. *In re Boesch*, 617 F.2d 272, 205 USPQ 215 (CCPA 1980).

Claims 3, 10-12, 24, and 31-33 are rejected under 35 U.S.C. 103(a) as being unpatentable over Gonsalves. Gonsalves, as applied above, is as set forth and incorporated herein. Gonsalves does not appear to specifically disclose a weight

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average molecular weight and level of silicon as claimed. However, Gonsalves does disclose adding monomer levels of the polysilsesquioxane at 1 to about 40% by weight (section 0063) to increase their reactive ion etch resistance (section 0064). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to have added a variety of amounts of polysilsesquioxane, including an amount that would produce a weight average molecular weight and level of silicon included in applicant's claimed ranges, through routine experimentation and optimization. A particular parameter must first be recognized as a result-effective variable, i.e., a variable which achieves a recognized result, before the determination of the optimum or workable ranges of said variable might be characterized as routine experimentation. *In re Boesch*, 617 F.2d 272, 205 USPQ 215 (CCPA 1980).

Regarding claims 24 and 31-33, Gonsalves discloses a photosensitive composition comprising the copolymer as claimed, a photoacid generator, and a solvent (Example 14 and Table 4).

Allowable Subject Matter

Claims 4, 5, 8, 9, 13-16, 19-21, 25, 26, 29, 30, 34-37, 40-43, 46-48, 51-59, 62-64 and 68 would be allowable if rewritten to overcome the rejection(s) under 35 U.S.C. 112, 2nd paragraph, set forth in this Office action and to include all of the limitations of the base claim and any intervening claims. Regarding claims 22-68, these claims are dependent on claim 22. Bonafini et al. and Gonsalves do not teach or disclose the instantly claimed limitations.

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Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Christopher M. Keehan whose telephone number is (571) 272-1087. The examiner can normally be reached on Monday-Friday, from 6:30 to 3:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Randy P. Gulakowski can be reached on 571-272-1302. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Christopher Keehan

September 23, 2004

Christopher Keehan At Unt 1712 Cess